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## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:

Jaime Poris

Assignee:

Nanometrics Incorporated

Title:

Method Of Measuring Dishing

Serial No.:

09/578,798

Filing Date:

May 23, 2000

Examiner:

Unknown

Group Art Unit:

Unknown

Docket No.:

M-8555 US

San Jose, California February 5, 2001

COMMISSIONER FOR PATENTS Washington, D. C. 20231

## INFORMATION DISCLOSURE STATEMENT UNDER 37 CFR § 1.97(b)

Dear Sir:

Pursuant to 37 C.F.R. § 1.56, § 1.97 and § 1.98, the documents listed on the accompanying PTO Form-1449 are called to the attention of the Examiner for the above patent application. Copies of these documents are enclosed.

Citation of these documents shall not be construed as:

- 1. an admission that the documents are necessarily prior art with respect to the instant invention;
  - 2. a representation that a search has been made; or
- 3. an admission that the information cited herein is, or is considered to be, material to patentability as defined in § 1.56(b).

I hereby certify that this correspondence is being deposited with the United States Postal Service as First Class Mail in an envelope addressed to: Commissioner for Patents, Washington, D.C. 20231, on February 5, 2001.

Attornay for Applicant

Date of Signature

Respectfully submitted,

Michael J. Halbert Attorney for Applicant

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Serial No. 09/578,798

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